

**SUPPLEMENTAL INFORMATION
DISCLOSURE STATEMENT**

BY APPLICANT

Docket: 6454-58227

App: 09/808,715

Applicant: Keefer et al.

Filed: March 14, 2001

Art Unit: 1745

U.S. PATENT DOCUMENTS

Init.*	Number	Date	Name	Class	Sub	Filed
Le	5,980,857	11/09/1999	Kapoor et al.	423	648.1	

FOREIGN PATENT DOCUMENTS

Le	WO 0076630	12/21/2000	PCT			
Le	62278770	03/12/1987	Japan (abstract)			


EXAMINER:

Hou Van Le

DATE

20 January 2004

*Examiner: Initial if considered, whether or not in conformance with MPEP 609; draw line through cite if not in conformance and not considered. Send copy.

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<div style="text-align: center;">  </div>							
Init.*		Number	Date	Name	Class	Sub	Filed
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